

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	144	(isolation sti (shallow adj trench) fox (field adj oxide)) same ((bur\$6 near (oxide dioxide insulat\$6)) box soi "silicon-on-insulator" "silicon on insulator") same (silicon near epitax\$8)	US-PGPUB; USPAT	OR	ON	2005/10/06 08:33
L2	1595	257/347.ccls.	USPAT	OR	OFF	2005/10/06 09:00
L3	734	257/347.ccls.	US-PGPUB	OR	OFF	2005/10/06 09:14
L4	15	("4646123"   "5349228"   "5475257"   "5804858"   "5841170"   "5889293"   "6051472"   "6091123"   "6110769"   "6121659"   "6136655"   "6156589"   "6245600"   "6451633"   "6476445").PN. OR ("6794716").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/10/06 09:30
L5	37	(isolation sti (shallow adj trench) fox (field adj oxide)) and ((bur\$6 near (oxide dioxide insulat\$6)) box soi "silicon-on-insulator" "silicon on insulator") and (silicon near epitax\$8)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/06 09:34
L6	3555	257/75.ccls. 257/347.ccls. 257/503.ccls. 257/506.ccls. 257/524.ccls.	US-PGPUB; USPAT	OR	OFF	2005/10/06 09:35
L7	188	L6 and (isolation sti (shallow adj trench) fox (field adj oxide)) and ((bur\$6 near (oxide dioxide insulat\$6)) box soi "silicon-on-insulator" "silicon on insulator") and (silicon near epitax\$8)	US-PGPUB; USPAT	OR	ON	2005/10/06 09:48
L8	114	((isolation sti (shallow adj trench) fox (field adj oxide)) and ((bur\$6 near (oxide dioxide insulat\$6)) box soi "silicon-on-insulator" "silicon on insulator" substrate wafer ic integrated circuit) and (silicon near epitax\$8)).clm.	US-PGPUB	OR	ON	2005/10/06 09:50